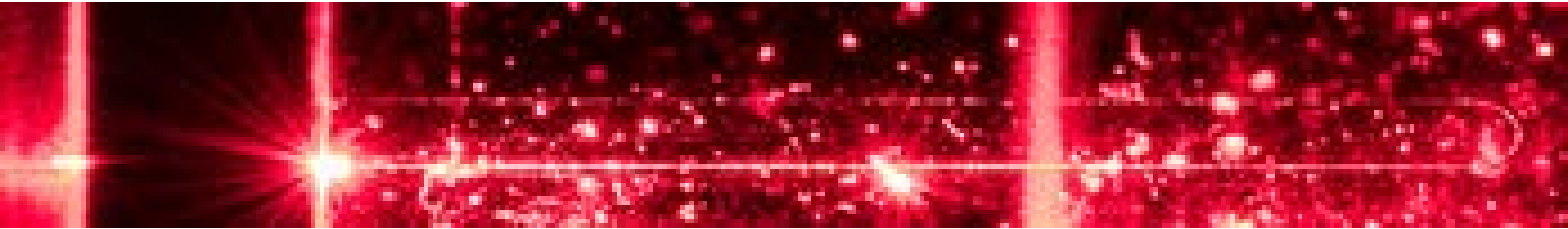


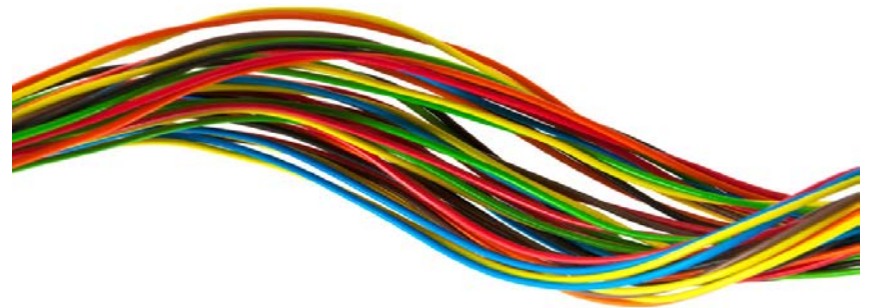
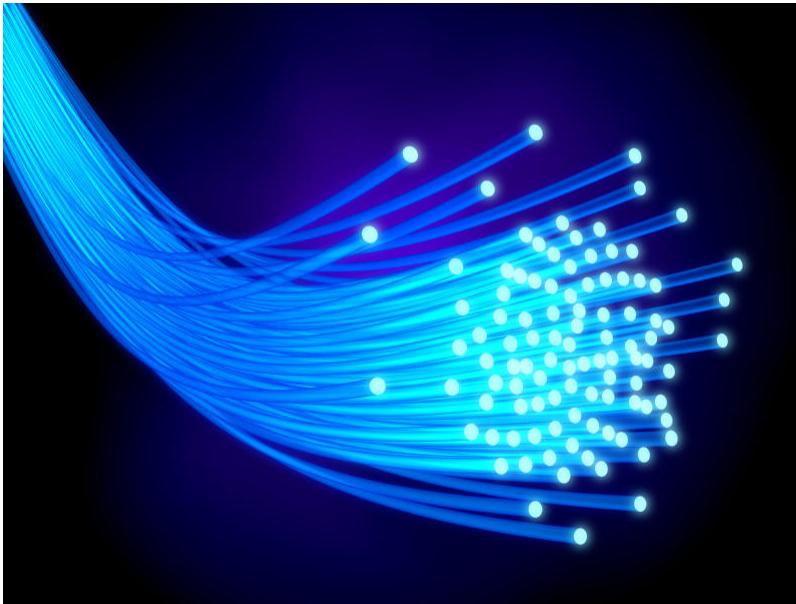
Direct Write Optical Waveguide Fabrication in Organic Films using a Heidelberg Laser Writer



Project by Ryan Moss
Advisor- Dr. Stefan Preble
Special Thanks Dr. Hirschman,
Dr. Ewbank, Dr. Pearson

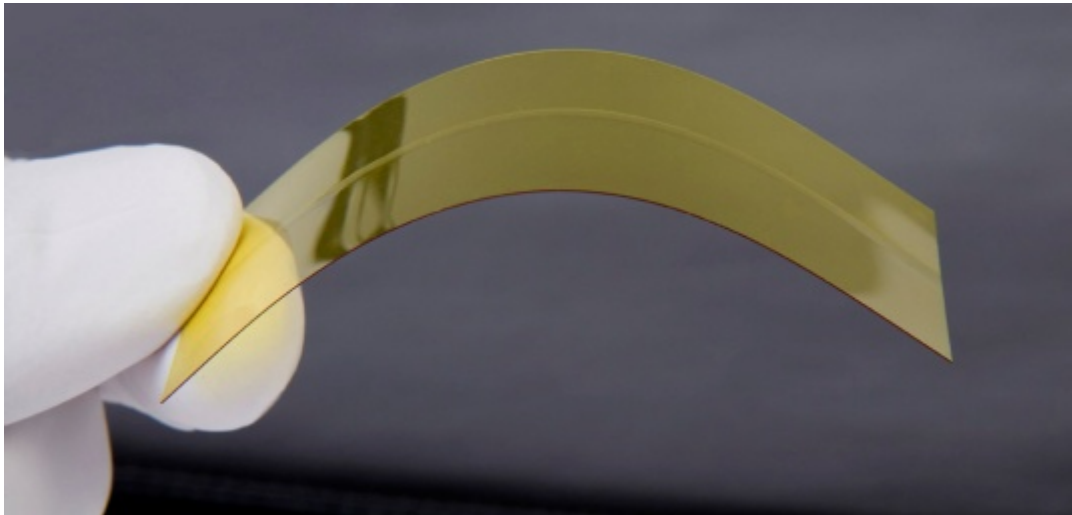
Optical vs. Electronic Interconnects

- Optical connections have a higher data density due to the high frequency of light.
- Lower power consumption



Organic/Printing Motivations

- Printing waveguides is a simple/ cheap way to fabricate onto any substrate
- Flexibility
- Biological Applications for throw away photonics



Material Selection

Waveguide (Photoresist Material)

Optical Properties- A high refractive index difference is good for coupling while a small difference is good at suppressing higher order modes.

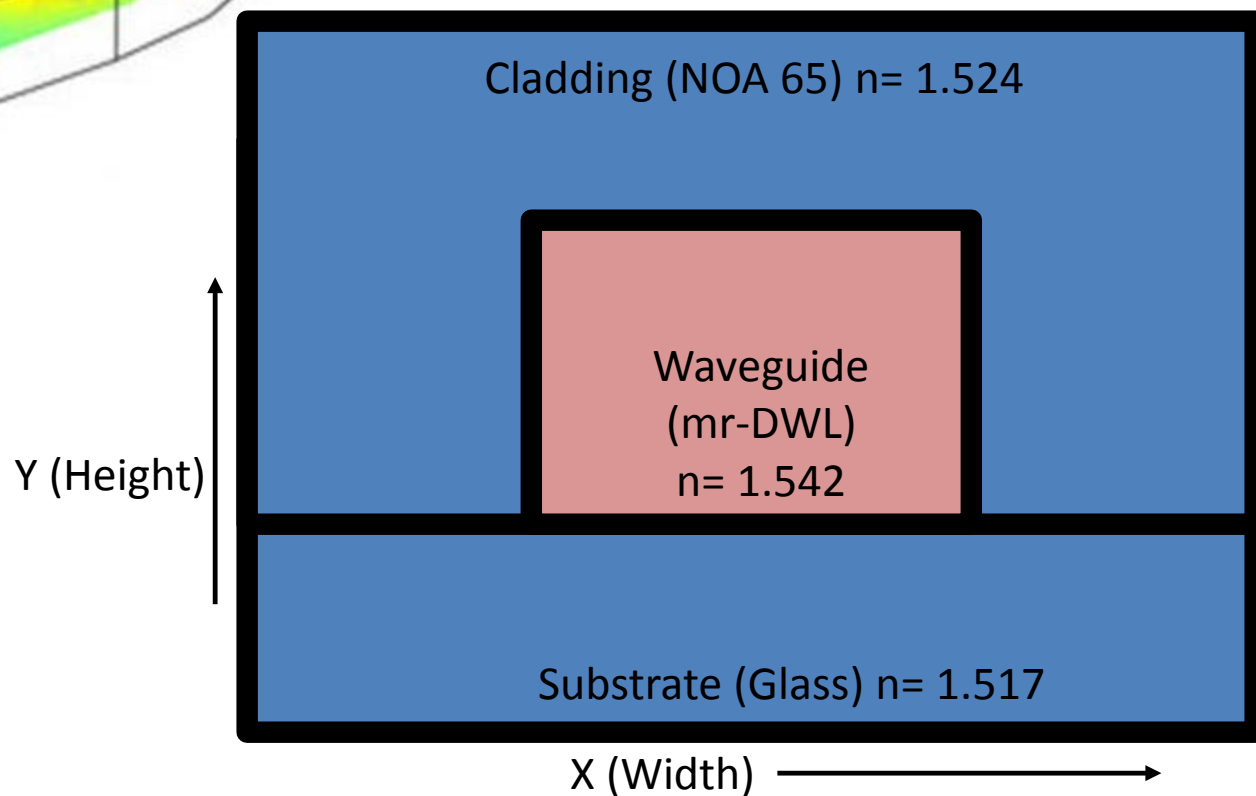
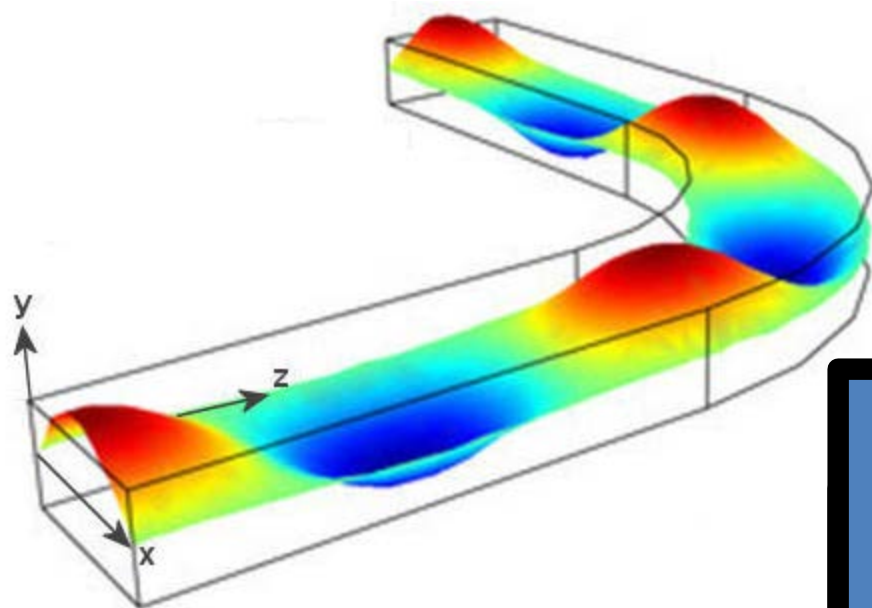
Exposure Requirement-

Heidelberg DWL 66+ (405nm),
Negative resist

Cladding (NOA 65)- Index should match substrate



Basic Design



Theory

Critical Angle

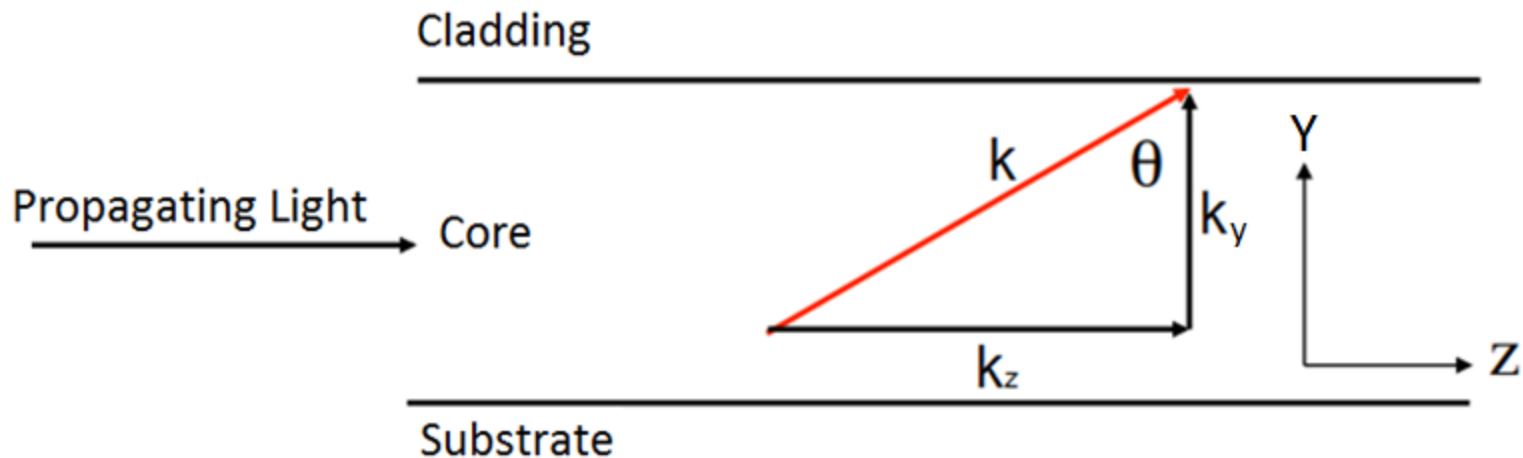
$$\theta_{c2} = \sin^{-1} \frac{n_s}{n_w}$$

$$\theta_{c1} = \sin^{-1} \frac{n_c}{n_w}$$

Resonant Modes

$$k_{x,y} = \frac{n_w \omega}{c} \cos \theta$$

$$k_z = \frac{n_w \omega}{c} \sin \theta$$



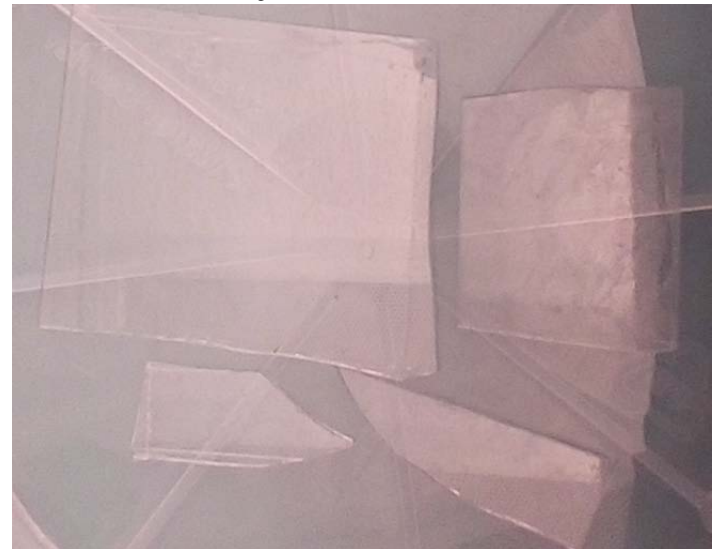
Fabrication

- 1) **Oxygen Plasma Surface Treatment**
- 2) **Coat mr-DWL-** 40mL/40mL dilution mr-DWL-5/SU-8 thinner

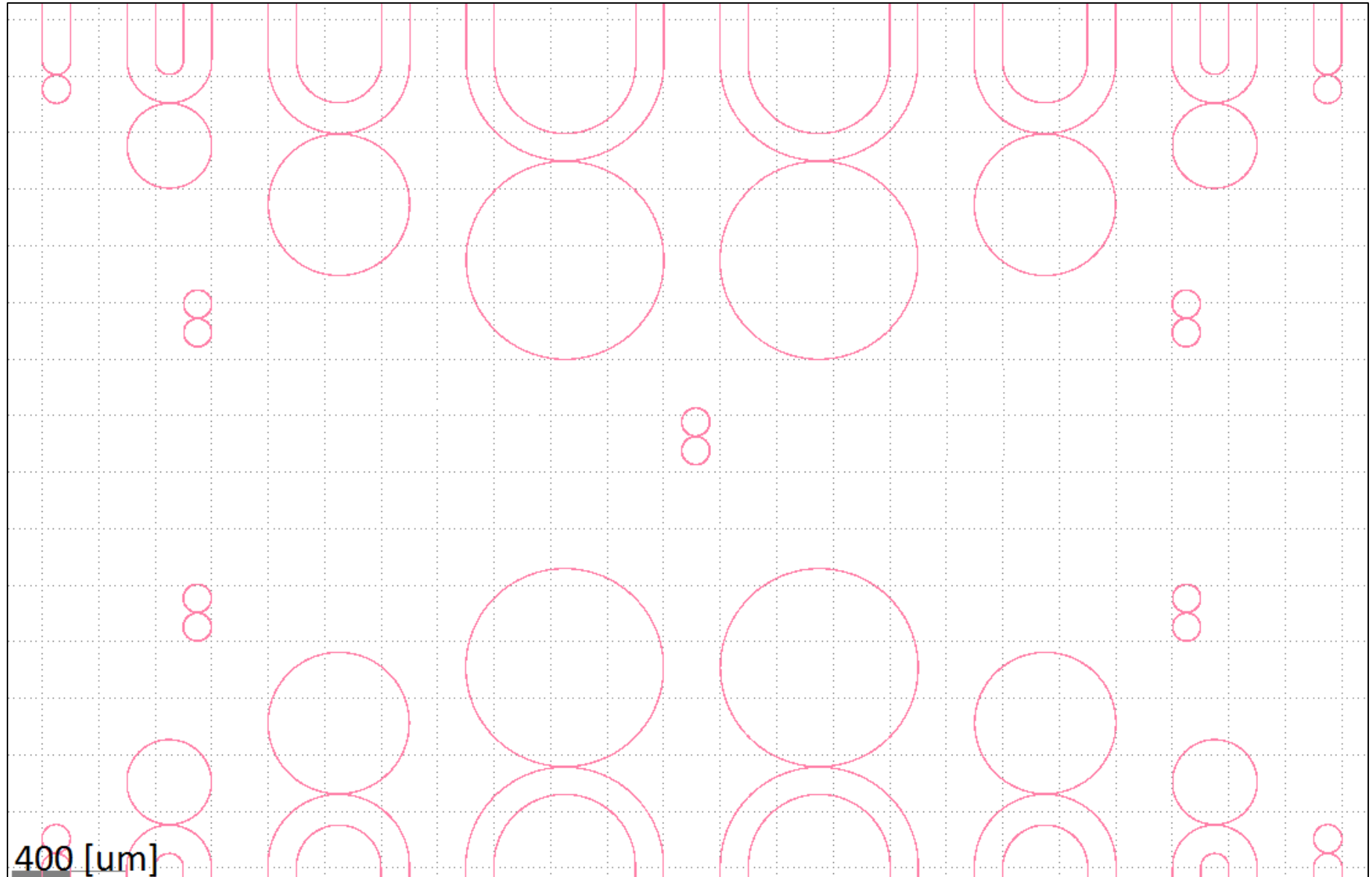
Spin Speed [rpm]	Thickness [um]
3000	1473
4000	1181
5000	1013

Post Application Bake	
Temperature [°C]	Time [min]
65	4

- 3) **Negative Exposure on Heidelberg**
 - Important Parameters- 60% Intensity, 200mW Power
- 4) **Post Exposure Bake-**1 minute 65°C followed by 3 minutes 95°C
- 5) **Development-** PGMEA 3.5 minutes.
- 6) **Cladding NOA 65**
 - Spin speed 3000rpm
 - UV flood cure 4.5[J/cm²]
- 7) **Scribe/Cleave....**



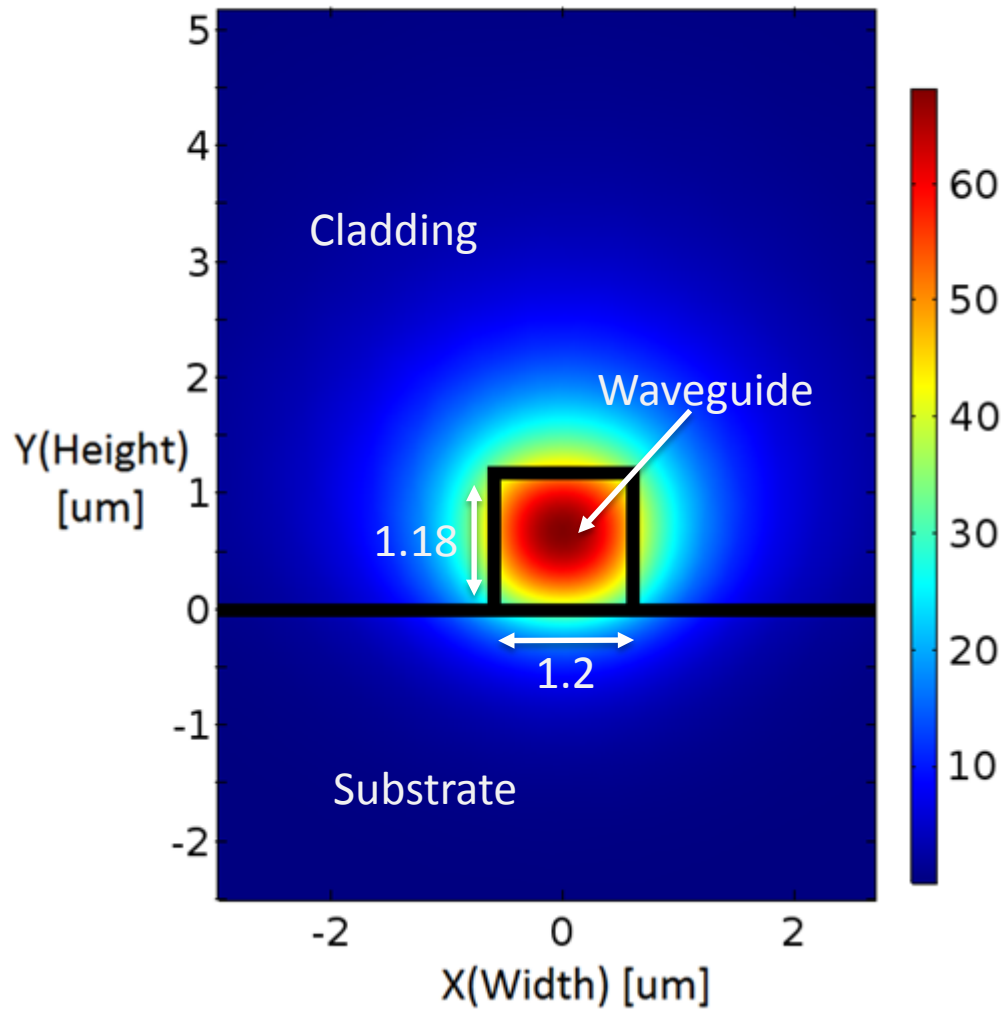
Final Layout



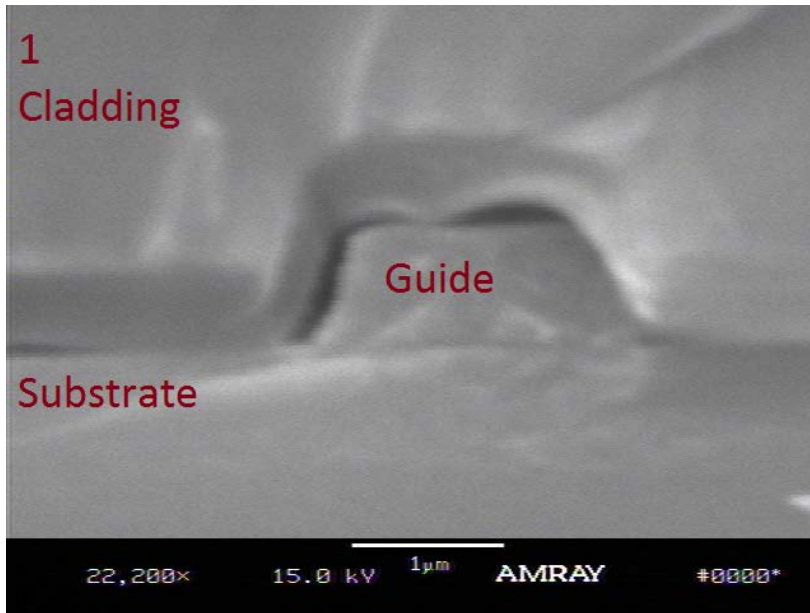
Simulation using Comsol

Surface Normal Electric Field [V/m]

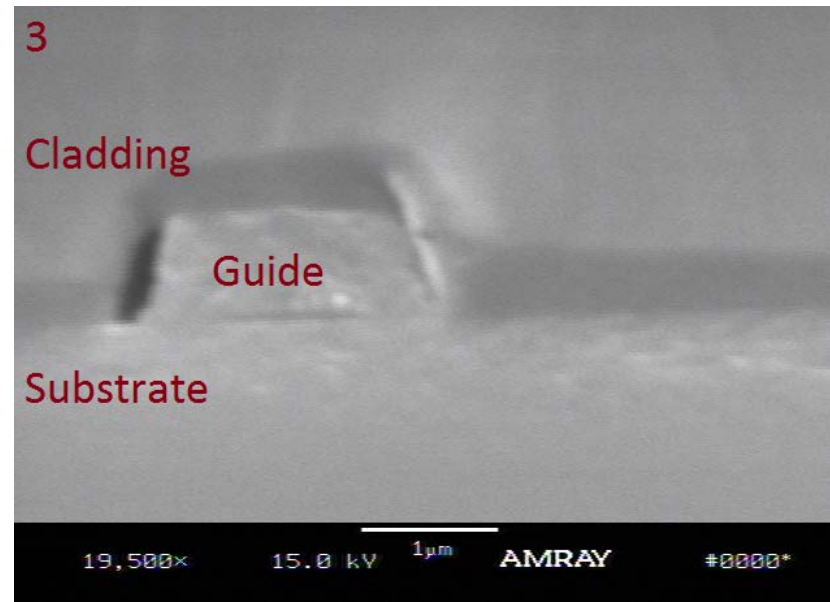
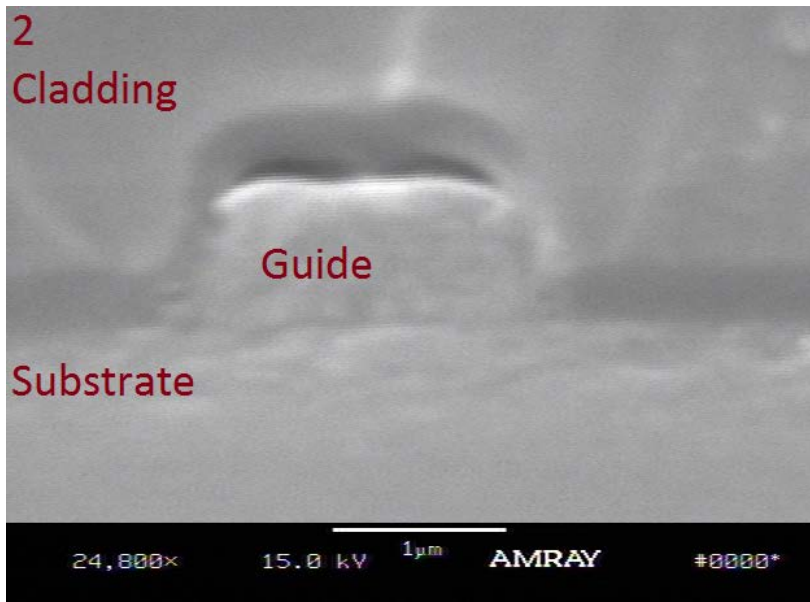
$$n_{\text{eff}} = 1.527$$



Scanning Electron Microscope

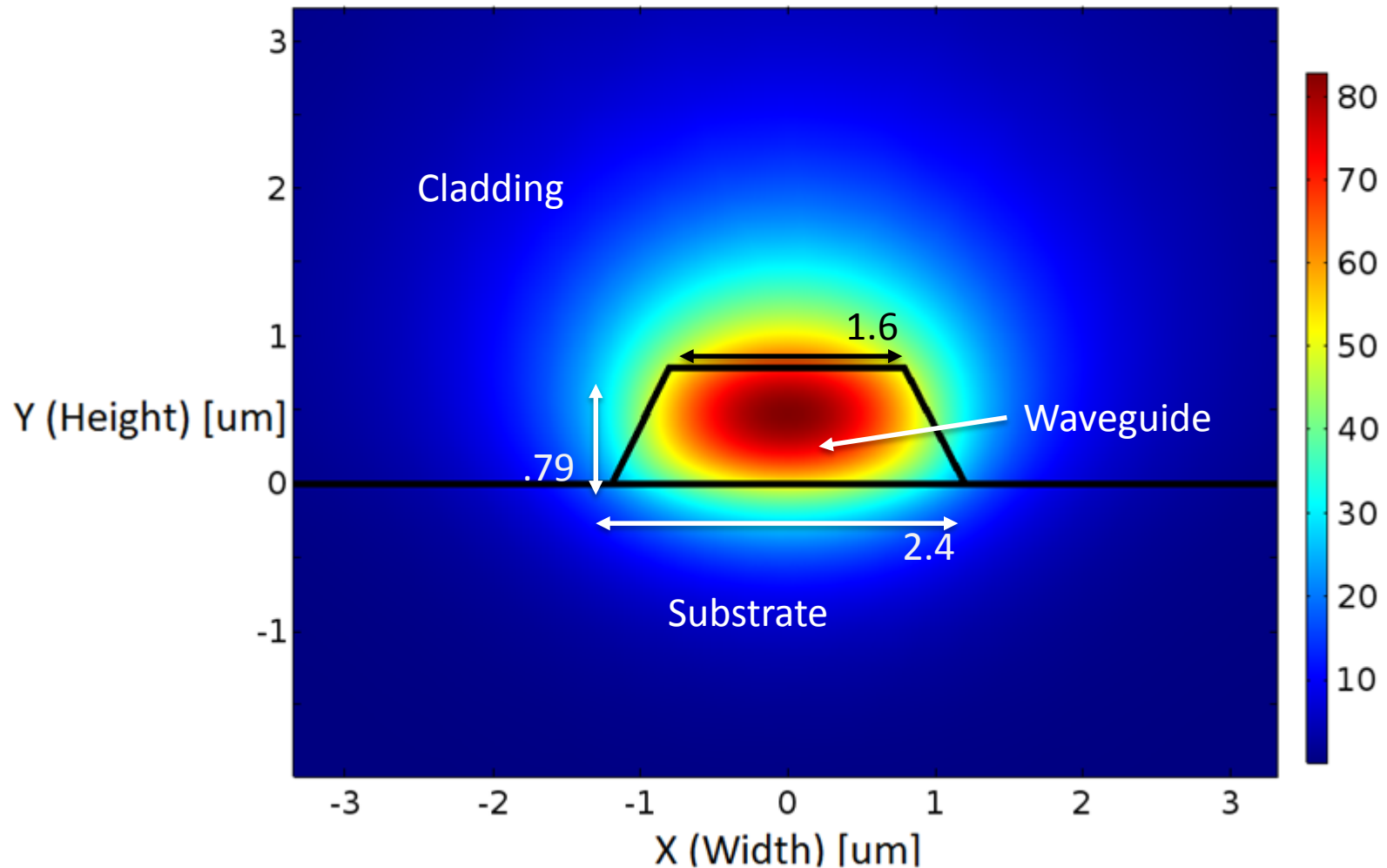


SEM Measurements [um]			
	1	2	3
Top	1.42	1.75	1.64
Bottom	2.35	2.41	2.50
Average Width	1.86	2.07	1.93
Average Height	0.79	0.79	0.79



Simulation 2 SEM

Surface Normal Electric Field
 $n_{\text{eff}} = 1.526$

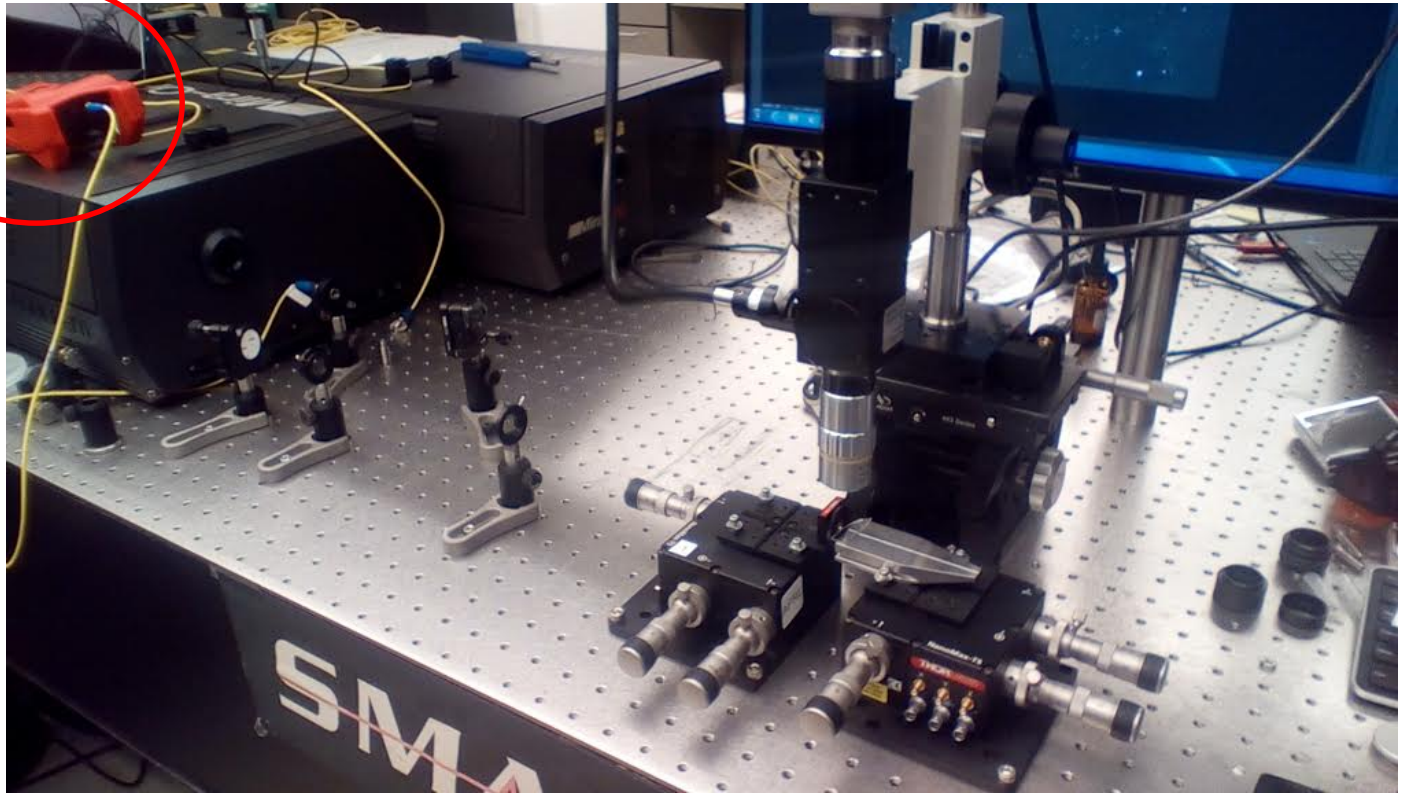


Testing

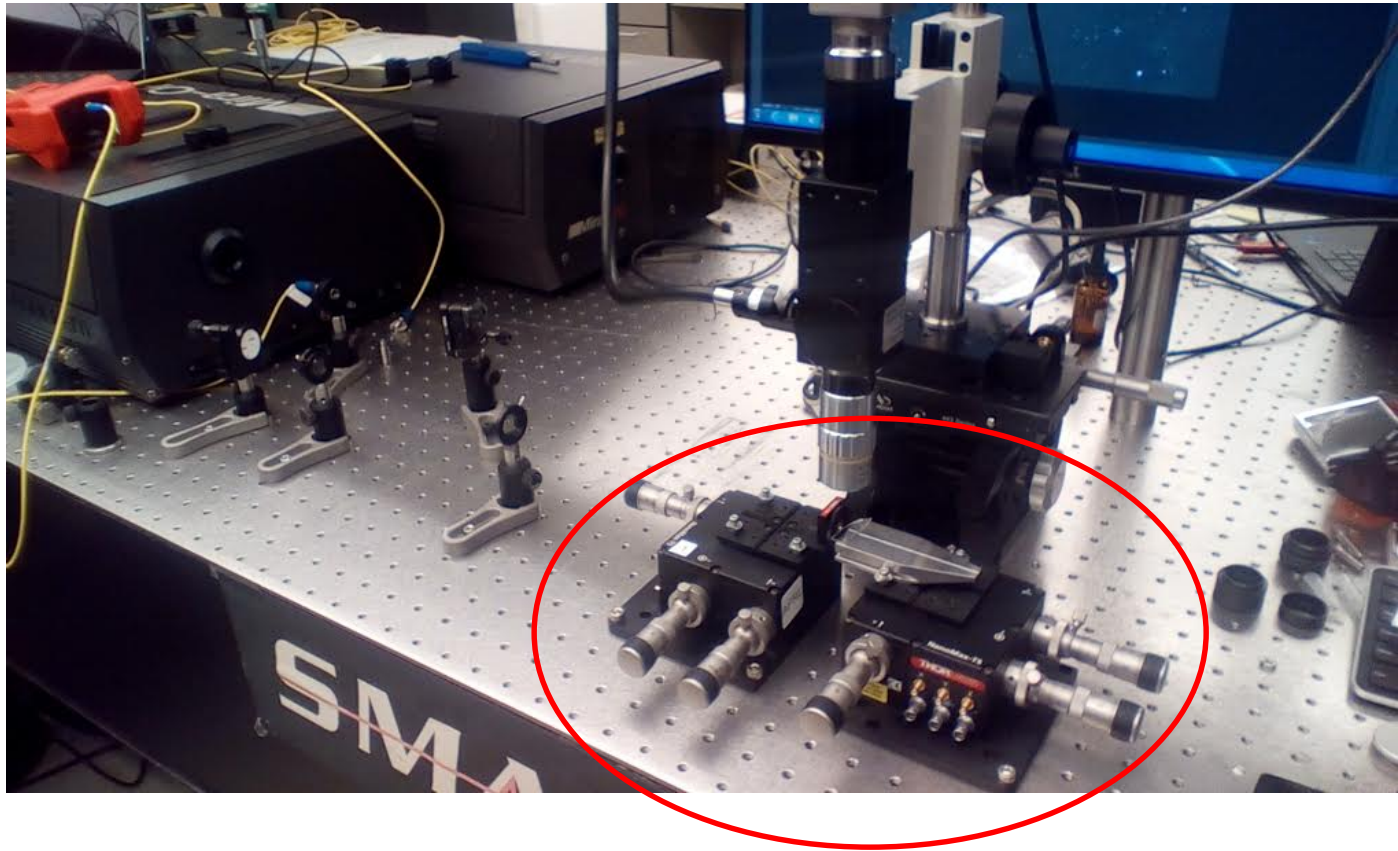
Light Source
Fisher Scientific



Outpower 1mW min
Wavelength 650nm Typ



Testing



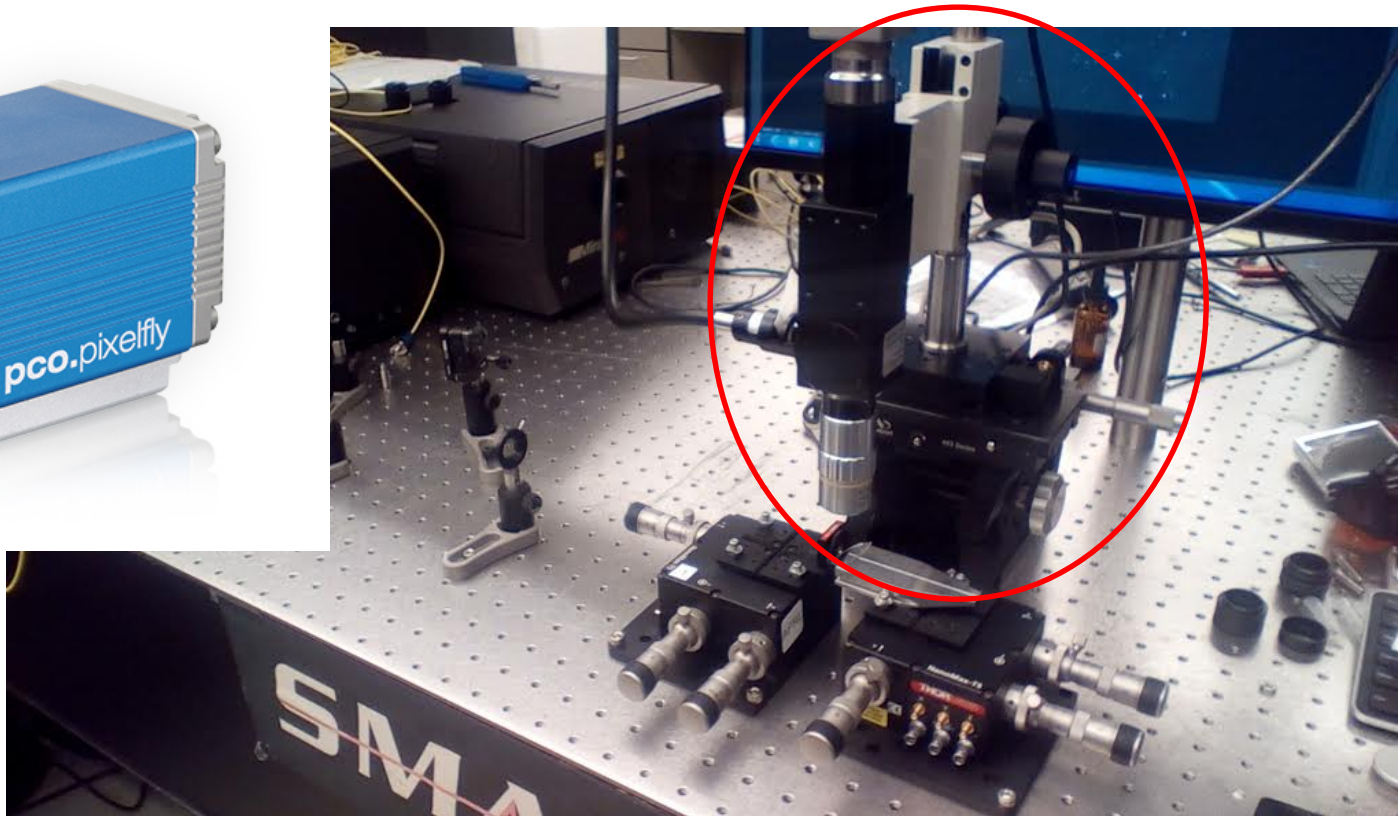
Focusing Lens stage

Lens is 4.5mm focal length
Initial beam alignment
Using X and Z controls

Sample Stage

Final coupling
Using movement in X,Y and Z (no
rotation controls)

Testing

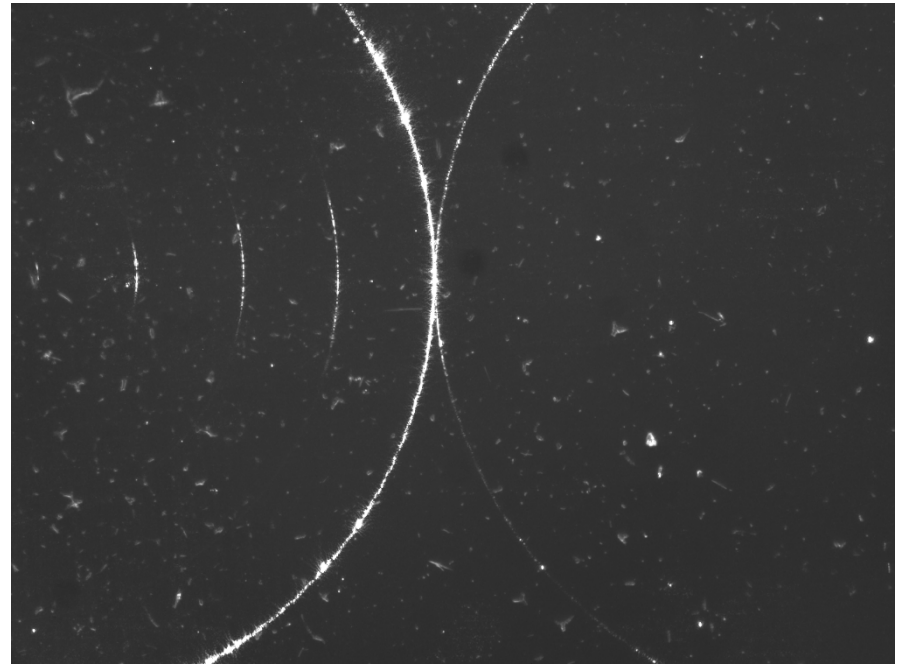
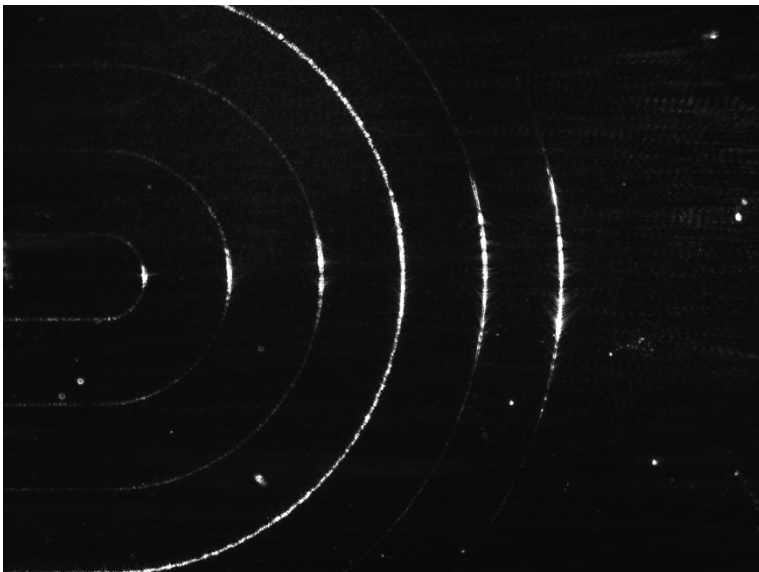
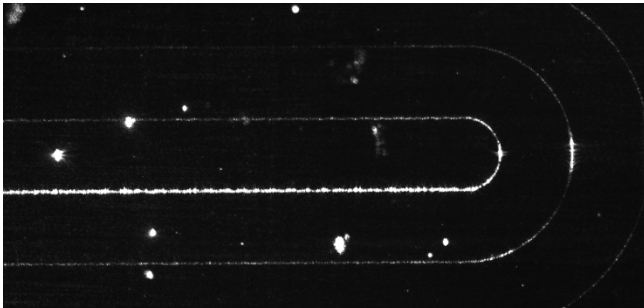


Microscope

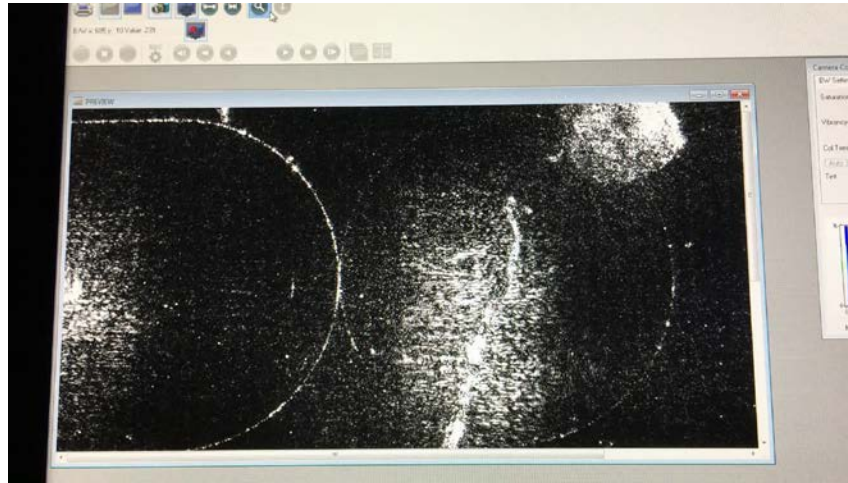
Pco.pixelfly camera mounted onto a microscope for alignment

Results

- Visual Results



Resonance!



- 350um radius with .9um nominal spacing

$$QualityFactor = \frac{\lambda}{\Delta\lambda}$$

- Quality Factor for T_e mode 75-90k
- Quality Factor for T_m mode 25-35k

Future

Next Step

- Optimization of processing and materials
- Acquisition of output data
- Additional optical devices

Long Range

- Short course for optical waveguide devices
- Additional substrates

Acknowledgements

RIT Nanophotonics Group



- Dr. Preble provided me with this project. His general mastery of optics was available to me throughout.



- Jeffrey Steidle was instrumental in getting the beam aligned and coupled into a waveguide.



- Michael Fanto provided the excellent visual picture for this presentation and was generally helpful

Acknowledgements



- Dr. Hirschman was instrumental in this project securing the Heidelberg tool for my use.
- He instructed me in it's use
- And was available for my general abuse throughout the project

Acknowledgements

Senior Design Faculty



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Acknowledgements SMFL

- Sean O'Brien did the certification on every tool I used during this project.
- He helped me using the SEM.
- And he is the most able to help using the Heidelberg direct write system
- The SMFL staff is great at what it does



Pictures from the internet

- <http://www.frankswebpace.org.uk/ScienceAndMaths/physics/physicsGCE/radioComms.htm>
- <http://www.ictxwavemedia.net/wordpress/2015/06/15/what-i>
- <http://joelynchelectrical.com/project/wiring-and-re-wiring/s-optical-fiber/>